

## Patent Assignment Abstract of Title

**Total Assignments: 1**

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**Title:** On-site cleaning gas generation for process chamber cleaning

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Search Results as of: 9/15/2003 1:08:44 P.M.

## WEST Search History

DATE: Monday, September 15, 2003

**Set Name Query**

side by side

**Hit Count Set Name**

result set

*DB=USPT,JPAB,EPAB,DWPI; PLUR=YES; OP=ADJ*

L3 L2 same gas\$5

78 L3

L2 (HF or (hydrofluoric acid) or (hydrogen fluoride)) same electrolysis  
same (fluorine or 'F.sub.2')

159 L2

L1 ((HF or hydrofluoric acid) with electrolysis) same (fluorine or  
'F.sub.2')

58 L1

END OF SEARCH HISTORY